

Amendments to the Claims:

This listing of claims will replace all prior versions, and listings, of claims in the application:

Listing of Claims:

1. (withdrawn) A method for removing contaminants from a surface of an object to be cleaned, the method comprising:
providing a cleaning device fluidically connected to a high-pressure gas supply, the device comprising at least one high-pressure passage of a predetermined miniature lateral scale with a high-pressure outlet for accelerating the gas, the high-pressure outlet characterized by at least one narrow lip, the outlet and the narrow lip defining an active surface;
bringing the active surface of the cleaning device to a predetermined miniature gap from, and substantially parallel to, the surface of the object to be cleaned, thus defining a throat section associated with the device between said at least one narrow lip and the surface of the object to be cleaned, wherein the gap is the width of the throat section;
accelerating the gas to about sonic speeds at the throat section;
thereby producing lateral aeromechanic removal forces that act on the contaminants.
2. (withdrawn) The method of claim 1, wherein the width of the throat section is reduced below a predetermined distance to attain a high gradient of velocity of the gas, thereby controlling mass flow.
3. (withdrawn) The method of claim 1, wherein the width of the throat section is regulated.
4. (withdrawn) The method of claim 1, wherein the width of the throat section is in the order of 100 to 1000 microns.

5. (withdrawn) The method of claim 1, wherein the width of the throat section is about 30 to 100 microns.
6. (withdrawn) The method of claim 1, wherein the width of the throat section is about 30 microns or less.
7. (withdrawn) The method of claim 1, wherein the narrow lip is sharp.
8. (withdrawn) The method of claim 1, wherein the lateral scale of the high-pressure passage is about the same in size as the width of the throat section.
9. (withdrawn) The method of claim 1, wherein the lateral scale of the high-pressure passage is significantly larger than the width of the throat section.
10. (withdrawn) The method of claim 1, wherein the lateral scale of the high-pressure passage is significantly smaller than the width of the throat section.
11. (withdrawn) The method of claim 1, wherein pressure of the high-pressure gas supply is regulated.
12. (withdrawn) The method of claim 1, wherein pressure of the high-pressure gas supply is up to 5 bars.
13. (withdrawn) The method of claim 1, wherein pressure of the high-pressure gas supply is up to 20 bars.
14. (withdrawn) The method of claim 1, wherein pressure of the high-pressure gas supply is up to 100 bars.
15. (withdrawn) The method of claim 1, further comprising evacuating the gas through at least one gas evacuation passage, confining said at least one high-pressure outlet within, and having external rims, provided in the device.
16. (withdrawn) The method of claim 15, wherein evacuating the gas through at least one gas evacuation passage is carried out by vacuum means.

17. (withdrawn) The method of claim 16, wherein the vacuum means and the high-pressure gas supply are both regulated to induce substantially zero pressure forces on the object to be cleaned.
18. (withdrawn) The method of claim 16, wherein the vacuum means evacuate substantially all the gas so that in effect a dynamically closed environment is formed substantially preventing mass flow of the gas with removed contaminants from escaping to ambient atmosphere.
19. (withdrawn) The method of claim 1, further comprising providing a relative motion between the active surface of the device and the surface of the object to be cleaned.
20. (withdrawn) The method of claim 19, wherein the relative motion is linear.
21. (withdrawn) The method of claim 19, wherein the relative motion is angular.
22. (withdrawn) The method of claim 20, wherein the relative motion is combined with linear motion.
23. (withdrawn) The method of claim 19, wherein the relative motion is substantially parallel to the surface and the direction of the gas as it accelerates in the throat section.
24. (withdrawn) The method of claim 1, wherein the active surface of the device is occasionally relocated from point to point to clean localized portions of the surface to be cleaned.
25. (withdrawn) The method of claim 1, wherein the width of the throat section is controlled using physical support.
26. (withdrawn) The method of claim 1, wherein the width of the throat section is controlled using non-contact support.
27. (withdrawn) The method of claim 26, wherein the non-contact support comprises air-cushioning.

28. (withdrawn) The method of claim 1, wherein the gas is air.
29. (withdrawn) The method of claim 1, wherein the gas is helium.
30. (withdrawn) The method of claim 1, wherein the gas is Nitrogen.
31. (withdrawn) The method of claim 1, wherein the gas is heated.
32. (withdrawn) The method of claim 1, wherein the surface to be cleaned is heated.
33. (withdrawn) The method of claim 1, wherein the gas is excited in high-frequency a periodic fluctuations.
34. (withdrawn) The method of claim 33, wherein the gas is excited by piezoelectrically.
35. (withdrawn) The method of claim 33, wherein the gas is excited by acoustically.
36. (currently amended) A cleaning device for removing contaminants from a surface of an object to be cleaned, the device adapted to be fluidically connected to a high-pressure gas supply, the device comprising:
a cleaning head comprising at least one high-pressure converging passage with a predetermined miniature lateral seal having a width of between 30 to 1000 microns, with a high-pressure outlet for accelerating the gas, the high-pressure outlet characterized by at least one narrow lip, the outlet and the narrow lip defining an active surface a surface where said at least one high pressure outlet is located,
a support mechanism for holding the object in a gap of between 30 to 1000 microns from the cleaning head,
whereby when the ~~active surface~~ surface where said at least one high pressure outlet is located of the cleaning device is brought to a predetermined ~~miniature~~ gap from, and substantially parallel to, the surface, thus defining a throat section between said at least one ~~narrow~~ lip and the surface of the object to be cleaned, wherein the gap is the width of the throat section, and when the gas is accelerated to about sonic speeds at the throat section, lateral aeromechanic removal forces are produced that act on the contaminants.

37. (currently amended) The device of claim 36, wherein the device is further provided with an adjustment mechanism capable of adjusting the width of the throat section is ~~controlled~~ adjustable by ~~[[a]]~~ mechanical means.
38. (currently amended) The device of claim 36, wherein the device is further provided with an adjustment mechanism capable of adjusting the width of the throat section is ~~controlled~~ adjustable by ~~[[an]]~~ aeromechanical means.
39. (currently amended) The device of claim 36, wherein the width of the throat section is ~~set to be~~ in the order of 100 to 1000 microns.
40. (currently amended) The device of claim 36, wherein the width of the throat section is ~~set to be~~ in the range of about 30 to 100 microns.
41. (currently amended) The device of claim 36, wherein the width of the throat section is ~~set to be~~ about 30 microns or less.
42. (currently amended) The device of claim 36, wherein the ~~narrow lip is sharp~~ has a pointed end.
43. (currently amended) The device of claim 36, wherein the ~~lateral-scale~~ width of the high-pressure passage is about the same in size as the width of the throat section.
44. (currently amended) The device of claim 36, wherein the ~~lateral-scale~~ width of the high-pressure passage is ~~significantly~~ larger than the width of the throat section.
45. (currently amended) The device of claim 36, wherein the ~~lateral-scale~~ width of the high-pressure passage is ~~significantly~~ smaller than the width of the throat section.
46. (currently amended) The device of claim 36, further provided with a pressure regulator for regulating the ~~wherein~~ pressure of the high-pressure gas supply ~~is regulated~~.
47. (currently amended) The device of claim ~~36~~ 46, wherein the pressure regulator may be regulated to provide pressure of the high-pressure gas supply ~~[[is]]~~ up to 5 bars.

48. (currently amended) The device of claim ~~36~~ 46, wherein the pressure regulator may be regulated to provide pressure of the high-pressure gas supply ~~[[is]]~~ up to 20 bars.
49. (currently amended) The device of claim ~~36~~ 46, wherein the pressure regulator may be regulated to provide pressure of the high-pressure gas supply ~~[[is]]~~ up to 100 bars.
50. (original) The device of claim 36, further comprising at least one gas evacuation passage.
51. (currently amended) The device of claim 50, wherein said at least one gas ~~evacuating~~ evacuation passage is connected to a vacuum pump.
52. (currently amended) The device of claim 36, further comprising a relative motion means, for providing relative motion between the ~~active surface~~ surface where said at least one high pressure outlet is located of the device and the surface to be cleaned.
53. (original) The device of claim 52, wherein the relative motion means provides linear motion.
54. (original) The device of claim 52, wherein the relative motion means provides angular motion.
55. (canceled)
56. (original) The device of claim 52, wherein the relative motion is provided by mechanical means.
57. (original) The device of claim 52, wherein the relative motion is provided by aeromechanical means.
58. (currently amended) The device of claim 36, wherein the ~~active surface~~ surface where said at least one high pressure outlet is located of the device is adapted to be occasionally relocated from point to point to clean localized portions of the surface to be cleaned.

59. (original) The device of claim 36, wherein the cleaning head unit is supported by mechanical means.
60. (original) The device of claim 36, wherein the cleaning head unit is supported by an air-cushion.
61. (currently amended) The device of claim 36, further comprising a support mechanism for holding ~~wherein~~ the object to be cleaned is ~~held~~ with contact by mechanical means.
62. (currently amended) The device of claim 36, further comprising a support mechanism for supporting ~~wherein~~ the object to be cleaned is ~~supported~~ by non-contact means.
63. (original) The device of claim 62, wherein the non-contact means comprises an air-cushion.
64. (original) The device of claim 36, wherein the cleaning head is integrated in a non-contact supporting platform.
65. (original) The device of claim 36, wherein the high-pressure outlet is elongated.
66. (original) The device of claim 65, wherein said at least one lip comprises at least two elongated lips, whereby two opposing throat sections are defined having substantially equal widths.
67. (original) The device of claim 65, wherein said at least one lip comprises at least two elongated lips, whereby two opposing throat sections are defined having different widths.
68. (original) The device of claim 65, wherein said at least one lip comprises at least two elongated lips, whereby two opposing throat sections are defined, and wherein the passage is substantially perpendicular to the surface of the object to be cleaned.

69. (original) The device of claim 65, wherein said at least one lip comprises at least two elongated lips, whereby two opposing throat sections are defined, and wherein the passage is tilted with respect to the surface of the object to be cleaned.
70. (original) The device of claim 36, wherein the high-pressure outlet is annular.
71. (currently amended) The device of claim 36, wherein the ~~active-surface~~ surface where said at least one high pressure outlet is located is flat.
72. (currently amended) The device of claim 36, wherein the ~~active-surface~~ surface where said at least one high pressure outlet is located is arcuate.
73. (currently amended) The device of claim 36, wherein the ~~active-surface~~ surface where said at least one high pressure outlet is located corresponds in shape to the shape of the surface of the object to be cleaned.
74. (original) The device of claim 36, wherein said at least one high-pressure passage includes a flow restrictor.
75. (original) The device of claim 74, wherein the flow restrictor exhibits self-adaptive return spring properties.
76. (original) The device of claim 75, wherein the flow restrictor is an electromechanical control valve.
77. (original) The device of claim 74, further provided with at least one gas evacuation passage, which includes a flow restrictor.
78. (original) The device of claim 36, comprising at least two high-pressure outlets, the outlets arranged in a substantially parallel orientation.
79. (original) The device of claim 36, comprising at least two high-pressure outlets, the outlets arranged in a substantially orthogonal orientation.

80. (currently amended) The device of claim 36, wherein at least one of said at least one high-pressure outlet is provided that is divided into sectors that can be operated separately.

81. (currently amended) The device of claim 36, comprising at least one of said at least one high-pressure outlet that can be relocated to a new operational location between two consecutive cleaning sequences.

82. (currently amended) The device of claim 36, comprising at least one of said at least one high-pressure outlet that is parallel to the object where the object is oriented without any respect to gravity.

83. (currently amended) A cleaning system for removing contaminants from a surface of an object to be cleaned, the system adapted to be fluidically connected to a high-pressure gas supply, the system comprising:

at least one cleaning head comprising at least one high-pressure converging passage with a predetermined miniature lateral scale having a width of between 30 to 1000 microns with a high-pressure outlet for accelerating the gas, the high-pressure outlet characterized by at least one ~~narrow~~ lip, the outlet and the ~~narrow~~ lip defining an surface where said at least one high pressure outlet is located active surface,

supporting means for supporting the object to be cleaned in a gap of between 30 to 1000 microns from the cleaning head;

relative motion means for providing relative motion between the surface of the object to be cleaned and said at least one cleaning head,

whereby when the ~~active surface~~ effective cleaning surface of the cleaning device is brought to a predetermined ~~miniature~~ gap from, and substantially parallel to, the surface, thus defining a throat section between said at least one ~~narrow~~ lip and the surface of the object to be cleaned, wherein the gap is the width of the throat section, and when the gas is accelerated to about sonic speeds at the throat section, lateral aeromechanic removal forces are produced that act on the contaminants.

84. (original) The system of claim 83, wherein the system is configured for round objects to be cleaned.
85. (original) The system of claim 83, wherein the system is configured for rectangular objects to be cleaned.
86. (original) The system of claim 83, wherein the supporting means comprises a platform that supports the object, at least partly, without contact by an air-cushion from at least one side.
87. (original) The system of claim 86, wherein the air-cushion is vacuum-preloaded.
88. (original) The system of claim 83, wherein the supporting means comprises a platform that supports the object, at least partly, with contact.
89. (currently amended) The system of claim 83, wherein the relative motion means comprises mechanical means employing friction are used to provide relative motion, by conveying the object.
90. (currently amended) The system of claim 83, wherein the relative motion means comprises mechanical means employing gripping of the object are used to convey the object in order to provide relative motion.
91. (currently amended) The system of claim 83, wherein said at least one cleaning head is movable in order to provide the relative motion.
92. (original) The system of claim 83, where said at least one cleaning head and the object to be cleaned are movable in order to provide the relative motion.
93. (currently amended) The system of claim 83, further comprising heating means for heating the gas or the surface of the object to be cleaned.
94. (original) The system of claim 93, wherein the heating means comprises a heater for heating the gas.

95. (original) The system of claim 93, wherein the heating means comprises a heater for heating the surface of the object to be cleaned.
96. (original) The system of claim 83, wherein wetting means are provided for wetting the surface to be cleaned, in order to reduce adhesive forces acting on the contaminants.
97. (original) The system of claim 83, wherein an ionizer is provided for ionizing the gas.
98. (original) The system of claim 83, wherein an actuator is provided for exciting the gas to high frequencies periodic fluctuations.
99. (original) The system of claim 83, wherein an optical scanner is provided for inspecting the surface to be cleaned and monitoring removal of contaminants.